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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/081,385	02/20/2002		Takenori Hirose	16869P-042900US	9702
20350	7590	11/09/2006		EXAMINER	
		TOWNSEND AN	LEE, HWA S		
TWO EMBARCADERO CENTER EIGHTH FLOOR SAN FRANCISCO, CA 94111-3834				ART UNIT	PAPER NUMBER
				2877	

DATE MAILED: 11/09/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

•		
	Application No.	Applicant(s)
	10/081,385	HIROSE ET AL.
Office Action Summary	Examiner	Art Unit
	Andrew Hwa S. Lee	2877
The MAILING DATE of this communication a Period for Reply	ppears on the cover sheet wit	th the correspondence address
A SHORTENED STATUTORY PERIOD FOR REP WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory perior - Failure to reply within the set or extended period for reply will, by state Any reply received by the Office later than three months after the main earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNIC 1.136(a). In no event, however, may a re of will apply and will expire SIX (6) MON tute, cause the application to become AB.	CATION. Apply be timely filed THS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).
Status		
	A	·
1) Responsive to communication(s) filed on 21		
<i>,</i> —	nis action is non-final.	
3) Since this application is in condition for allow closed in accordance with the practice under		
Disposition of Claims		
4)⊠ Claim(s) <u>60-65</u> is/are pending in the applicat	ion.	
4a) Of the above claim(s) is/are withdr		
5) Claim(s) is/are allowed.		
6)⊠ Claim(s) <u>60-65</u> is/are rejected.		
7) Claim(s) is/are objected to.	•	
8) Claim(s) are subject to restriction and	/or election requirement.	
Application Papers	·	
9) The specification is objected to by the Exami	ner	
10) The drawing(s) filed on is/are: a) a		ov the Examiner
Applicant may not request that any objection to the		
	• • • • • • • • • • • • • • • • • • • •	
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the		
,—	Examiner. Note the diagnost	omos volicii di fami i 10 faz.
Priority under 35 U.S.C. § 119	an priority under 25 U.S.C. S	(110(a) (d) or (f)
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:	•	119(a)-(d) or (i).
1. Certified copies of the priority docume		antication No.
2. Certified copies of the priority docume		
 Copies of the certified copies of the pr application from the International Bure 		received in this National Stage
* See the attached detailed Office action for a li		received.
2 - 2 - 11 - 11 - 11 - 11 - 11 - 11 - 1	•	
e e		
Attachment(s)		
1) Notice of References Cited (PTO-892)		Summary (PTO-413)
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	·	s)/Mail Date
3) Information Disclosure Statement(s) (PTO/SB/08)	5) ☐ Notice of Ir 6) ☐ Other	nformal Patent Application

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DETAILED ACTION

Remarks

1. Applicant's election without traverse of claims 60-65 in the reply filed on 8/21/06 is acknowledged. In view of the recent Interim Guidelines on Patent Eligible Subject Matter (MPEP 2106) a rejection under 35 U.S.C. 101 follows:

Claim Rejections - 35 USC § 101

2. 35 U.S.C. 101 reads as follows:

Whoever invents or discovers any new and useful process, machine, manufacture, or composition of matter, or any new and useful improvement thereof, may obtain a patent therefor, subject to the conditions and requirements of this title.

35 U.S.C. 101 reads as follows:

Whoever invents or discovers any new and useful process, machine, manufacture, or composition of matter, or any new and useful improvement thereof, may obtain a patent therefor, subject to the conditions and requirements of this title.

Claims 60-65 are rejected under 35 U.S.C. 101 because the claimed invention is directed to non-statutory subject matter.

The claims are directed to a judicial exception; as such, pursuant to the Interim Guidelines on Patent Eligible Subject Matter (MPEP 2106)), the claims must have either physical transformation and/or a useful, concrete and tangible result. The claims fail to include transformation from one physical state to another. Although, the claims appear useful and concrete, there does not appear to be a tangible result claimed. Merely measuring would not appear to be sufficient to constitute a tangible result, since the outcome of the measuring step has not been used in a disclosed practical application nor made available in such a manner that its

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usefulness in a disclosed practical application can be realized. As such, the subject matter of the claims is not patent eligible.

Claim Rejections - 35 USC § 112

- 3. The following is a quotation of the second paragraph of 35 U.S.C. 112:
 - The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 4. Claim 60 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. The variable "n" is defined in the specification as the refractive index, however it is not defined in the claim.

Double Patenting

5. The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. A nonstatutory obviousness-type double patenting rejection is appropriate where the conflicting claims are not identical, but at least one examined application claim is not patentably distinct from the reference claim(s) because the examined application claim is either anticipated by, or would have been obvious over, the reference claim(s). See, e.g., *In re Berg*, 140 F.3d 1428, 46 USPQ2d 1226 (Fed. Cir. 1998); *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and *In re Thorington*, 418 F.2d 528, 163 USPO 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) or 1.321(d) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent either is shown to be commonly owned with this application, or claims an invention made as a result of activities undertaken within the scope of a joint research agreement.

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

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6. Claims 60-65 are rejected on the ground of nonstatutory obviousness-type double patenting as being unpatentable over claims 3-6 of U.S. Patent No. 7,119,908. Although the conflicting claims are not identical, they are not patentably distinct from each other because:

U.S. Patent No. 7,119,908 shows

determining plural measurement points on said wafer by frequency analysis or fitting for measuring the film thickness (first clause); and

measuring the film thickness at the measurement points

U.S. Patent No. 7,119,908 does not expressly state that the measurement points are successively irradiated; however, this would be an inherent step as light must be irradiated onto each measurement point.

Claim Rejections - 35 USC § 102

7. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 8. Claims 60-65 are rejected under 35 U.S.C. 102(e) as being anticipated by Nomoto et al (U.S. Patent No. 7,119,908).

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Nomoto et al shows:

determining plural measurement points on said wafer by frequency analysis or fitting for measuring the film thickness (first clause); and

measuring the film thickness at the measurement points

Nomoto et al do not expressly state that the measurement points are successively irradiated; however, this would be an inherent step as light must be irradiated onto each measurement point.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Andrew Hwa S. Lee whose telephone number is 571-272-2419.

The examiner can normally be reached on Tue-Fr.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory J. Toatley Jr. can be reached on 571-272-2800 ext 77. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Andrew Hwa S. Lee Primary Examiner

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